

IN THE PATENT AND TRADEMARK OFFICE

In re patent application of:	)	Group Art Unit: 2813
	)	
	)	Examiner: Schillinger, Laura
For: Process For High-Dielectric Constant	)	
Metal-Insulator Metal Capacitor In VLSI	)	
Multi-Level Metallization Systems	)	
	)	
Prior Application Number:	)	
09/891324	)	Attorney Docket:
	)	10004808-1
Continuation Prosecution Date:	)	
October 22, 2003	)	
	)	
Prior Application Filing Date:	)	Palo Alto, CA
June 27, 2001	)	October 22, 2003
	)	

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PRELIMINARY AMENDMENT

Commissioner of Patent and Trademarks  
Assistant Commissioner for Patents  
Washington, DC 20231


Sir:

Please enter this amendment prior to examination of this continuing application.

AMENDMENT

Please cancel claims 14-19 without prejudice.

Respectfully Submitted,

  
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